PTO/SB/08A (08-03)

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Sheet 1

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(Use as many sheets as necessary)

of 2

Complete if Known				
Application Number	10/616,492			
Filing Date	07/08/2003			
First Named Inventor	Yao-Sheng Lee			
Art Unit	1763			
Examiner Name				
Attorney Docket Number	074361.00015			

			U. S. PATENT	DOCUMENTS	
Examiner Initials*	Cite No. ¹	Document Number Number-Kind Code ^{2 (f known)}	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
BY		^{US-} 6,350,390	02-26-2002	Liu et al.	
1		^{US-} 6,514,378	02-04-2003	Ni et al.	
		^{US-} 5,545,290	08-13-1996	Douglas	
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Examiner Cite Foreign Patent Document No.1			Publication Date	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines,	Τ
	Country Code ³ Number ⁴ Kind Code ⁵ (if known)	MM-DD-YYYY	Applicant of Orleg Document	Where Relevant Passages Or Relevant Figures Appear	70	
134		JP 09050983	02-18-1997	Fujitsu Ltd.	,	
5		JP 09162164	06-20-1997	Fujitsu Ltd.		
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	l					Γ-

Examiner	0 1 7	Date	-11-11-
Signature	binh Ivan	Considered	I 5/25/∆5
<u> </u>		Considered	

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AM	10 10 10 11 1770 170	,		Application Number	10/616,492	
INFORMATION DISCLOSURE				Filing Date	07/08/2003	
STATEMENT BY APPLICANT		First Named Inventor	Yao-Sheng Lee			
				Art Unit	1763	
(Use as many sheets as necessary)		Examiner Name				
Sheet	2	of	2	Attorney Docket Number	074361.00015	

		NON PATENT LITERATURE DOCUMENTS	
Examiner Initials*	Cite No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T²
131		S. OKU, Y. SHIBATA, and K. OCHIAI, "Controlled Beam Dry Etching of InP by Using Br2-N2 Gas," J. Electron Mater., Vol 25, pp. 585-591,1996.	
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		D. LISHAN, J. LEE, and G. KIM, "InP Processing Using an HBr High Density ICP Plasma", GaAs MANTECH Digest of Papers - 2001, pp 175-178	
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Examiner Signature	Binh Tran	Date Considered	5/25/05

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